## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Young Sun Hwang et al.	) I hereby certify that this paper and the documents referred to as enclosed
Serial No.: To be assigned	therewith are being deposited with the United States Postal Service as first clas
Filed: November 21, 2003 (Herewith)	) mail, postage prepaid, on November 21 ) 2003, in an envelope addressed to
For: Methods for Forming Fine Photoresist Patterns	Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450
Group Art Unit: To be assigned	) Michael R. Hull
Examiner: To be assigned	Reg. No. 35,902 Attorney for Applicant
	)
	) .

## INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

Submitted herewith for consideration by the examiner is a copy of the document identified on the attached Form PTO-1449. Entry and consideration of the submitted document is solicited.

The Commissioner is authorized to charge any fee deficiency required by this paper, or credit any overpayment, to Deposit Account No. 13-2855.

Respectfully submitted,

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November 21, 2003

By:/

Michael R. Hull Reg. No. 35,902

For m PTO-1449 (Modified)	U.S. Department of Commerce	Atty. Docket No.	Serial No.	
,	Patent and Trademark Office	30205/39513	To be Assigned	
		Applicant		
INFORMATION DIS	CLOSURE STATEMENT	Young Sun Hwang et al.		
		Filing Date	Group	
		November 21, 2003	To be Assigned	

U.S. PATENT DOCUMENTS							
*Examiner Initials		Document Number	Issue Date	Name	Class	Subclass .	Filing Date if Appropriate
		6,541,361 B2	04/01/2003	Ko et al.			

	F	OREIGN PA	TENT DO	CUMENT	S		
*Examiner Initials	Document Number	Publication Date	Country	Class	Subclass	Translation	
						Yes	No
	11307437	11/05/1999	Japan			Abstract Only	
					•		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)					

EXAMINER		DATE	<b>CONSIDERED</b>	

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.